Photophysics of GaN single-photon emitters in the visible spectral range

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Photophysics of GaN single-photon emitters in the visible spectral range

Amanuel M. Berhane,1 Kwang-Yong Jeong,2,3 Carlo Bradac,1 Michael Walsh,2 Dirk Englund,2 Milos Toth,1 and Igor Aharonovich1,*

1School of Mathematical and Physical Sciences, University of Technology Sydney, Ultimo, New South Wales, 2007, Australia
2Department of Electrical Engineering and Computer Science, MIT, Cambridge, Massachusetts 02139, USA
3Department of Nano Science and Technology, Gachon University, Gyeonggi-do 13120, Republic of Korea

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In this work, we present a detailed photophysical analysis of recently discovered, optically stable single-photon emitters (SPEs) in gallium nitride (GaN). Temperature-resolved photoluminescence measurements reveal that the emission lines at 4 K are three orders of magnitude broader than the transform-limited width expected from excited-state lifetime measurements. The broadening is ascribed to ultrafast spectral diffusion. The photophysical study on several emitters at room temperature (RT) reveals an average brightness of \((427\pm215)\) kCounts/s. Finally, polarization measurements from 14 emitters are used to determine visibility as well as dipole orientation of defect systems within the GaN crystal. Our results underpin some of the fundamental properties of SPEs in GaN both at cryogenic and RT, and define the benchmark for future work in GaN-based single-photon technologies.

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I. INTRODUCTION

Single-photon emitters (SPEs) are fundamental building blocks for application in quantum communication [1], quantum cryptography [2], quantum states distribution [3,4], and information processing [5–7]. Single photons can be produced using nonlinear processes such as spontaneous parametric down conversion [8,9]; on-demand single photons can also be generated using quantum dots [10,11], single molecules [12,13], or defects in solids [5,14]. The latter are promising candidates for scalable quantum nanophotonics and for studying light-matter interaction as they can be easily integrated into photonic crystals and waveguides [14–18]. In particular, SPEs operating at room temperature are extremely desirable for practical devices. Among the most studied room-temperature SPEs, color centers in diamond [7,18–21], silicon carbide [22–25], zinc oxide [26–28], and—more recently—hexagonal boron nitride [29] are shaping the field. Concurrently, there is a growing push toward identifying and characterizing new emitters with analogous or even superior properties and in material systems with well-established growth and nanofabrication protocols.

Gallium nitride (GaN) is one such material. For instance, GaN quantum dots (QDs) have been incorporated into nanoscale pillars to generate bright single-photon sources in the UV spectral range at cryogenic temperatures and, to some extent, at room temperature (RT) [30–32]. It has also recently been shown that defects in GaN can act as polarized, bright SPEs that operate at RT emitting in the visible [33,34] and telecom spectral range [35]. While the origin of the SPEs is still under debate, it is believed these are point defects located near cubic inclusions in a hexagonal lattice. These SPEs are observed in commercial wafers, which are important for integration with optoelectronic devices and circuits. However, more work is needed to improve our current understanding of the photophysics, atomic structure, and technological potential of SPEs in GaN. In particular, understanding their level structure and the performance at cryogenic temperatures is important before these emitters can be used to perform advanced quantum optics experiments such as photon interference and entanglement.

In this work, we perform a detailed photophysical analysis of optically stable SPEs in GaN. We present cryogenic-temperature spectroscopic data, and a room-temperature analysis of the saturation behavior and transition kinetics for these emitters can be used to perform advanced quantum optics experiments for a range of emitters; we also provide detailed polarization measurements at RT.

II. EXPERIMENTAL SETUP

The sample used in this study is a commercially available 4-µm (2-µm p-type/2-µm undoped) GaN crystal grown on sapphire, obtained from Suzhou Nanowin Science and Technology Co., Ltd. The cryogenic-temperature measurements are carried out by placing the sample on an XYZ piezo stage, located in a closed-cycle Montana cryostat system with temperature control down to 4 K. All spectroscopy and second-order correlation measurements are carried out using a confocal microscope with an integrated Hanbury-Brown and Twiss interferometer. A cw laser (wavelength 532 nm) is used for excitation. The beam is focused to a spot size of \(\sim400\) nm through a 100× objective with a numerical aperture (NA) of 0.9. RT polarization spectroscopy is carried out using the confocal microscope where the polarization of the excitation laser is controlled by placing a half-wave plate into the optical path, while a visible polarizer is used in collection to monitor the emission polarization. Quarter-wave plates are used both on the excitation and detection paths to correct for birefringent components. Lifetime measurements are carried out using a pulsed laser (pulse width 32 ps) with a wavelength of 532 nm.

*Corresponding author: igor.aharonovich@uts.edu.au
are photostable, as illustrated by the fluorescence time-trace ZPL with very weak coupling to the PSB. The emitters most of the emission from GaN emitters comes from the Fig. S1 (see Supplemental Material [36]). This indicates that to phonon sidebands (PSB) of E1, E2, and E3, the respective (2.3 meV), respectively. To better visualize the ZPL coupling 1.796 eV (1.6 meV), 1.852 eV (2.4 meV), and 1.981 eV (3.9 ± 1.12) meV. All measurements were taken with an excitation laser power of 100 μW. (d)–(f) Second-order autocorrelation measurements for the three emitters labeled E1–E3 in (a) under an excitation power of 50 μW over long delay times. Inset are the g^2(τ) functions of the same emitters near zero delay time. The curves are fitted with three-level, second-order autocorrelation functions and show that the emitters E1–E3 are single photon emitters with g^2(τ = 0) values: 0.36, 0.48, and 0.31, respectively.

III. RESULTS AND DISCUSSION

We start by surveying single emitters at cryogenic temperatures. Figure 1(a) shows spectra for six emitters selected at random using an excitation laser power of 100 μW, at 4 K. A distinct zero-phonon line (ZPL) is obtained for each one of the emitters. The distribution of ZPL peak energy is shown in Fig. 1(b) and was obtained by analyzing a total of 19 emitters. The ZPL position ranges from 1.736 to 1.983 eV with a mean of (1.869 ± 0.064) eV. The histogram is similar to that reported for RT GaN (which has a mean of ~1.824 eV) [33], illustrating that the mechanism responsible for the observed ZPL energy range is unaffected by temperature. This is consistent with—and expected from—the interpretation that the energy range corresponds to variations in the positions of individual emitters in cubic inclusions in wurtzite GaN [33]. A histogram of the full width at half maximum (FWHM) of the 19 emitters at 4 K is shown in Fig. 1(c) with the mean linewidth of (3.9 ± 1.12) meV, which is approximately 7 times smaller than the previously measured mean linewidth at RT [33]. The additional narrow peak seen at 1.789 eV in Fig. 1(a) (indexed with asterisk) is the Cr impurity emission from the sapphire substrate.

To further characterize the SPEs, we focus on emitters E1, E2, and E3 which approximately span the observed ZPL range, as indicated in Fig. 1(a), and have ZPL FWHMs of 1.796 eV (1.6 meV), 1.852 eV (2.4 meV), and 1.981 eV (2.3 meV), respectively. To better visualize the ZPL coupling to phonon sidebands (PSB) of E1, E2, and E3, the respective spectra are replotted on the logarithmic y axis as shown in Fig. S1 (see Supplemental Material [36]). This indicates that most of the emission from GaN emitters comes from the ZPL with very weak coupling to the PSB. The emitters are photostable, as illustrated by the fluorescence time-trace measurements shown in Fig. S2 [36]. Figures 1(d)–1(f) show second-order autocorrelation measurements for correlation times of up to 15 μs, with the inset showing corresponding short-delay time g^2(τ = 0) characteristics. Fitting the second-order autocorrelation measurements for the three emitters with Eq. (1) yields g^2(τ = 0) values for of 0.36, 0.48, and 0.31, respectively. The deviations from zero are due to background fluorescence and detector jitter (~600 ps). The data can be fitted optimally with minimum chi-squared by a three-level model with a long-lived metastable state [34]:

\[
g^2(\tau) = 1 - (1 + a)e^{-|\tau_1|/\tau_1} + ae^{-|\tau_2|/\tau_2},
\]

where a, τ_1, and τ_2 are the branching ratio of rate coefficients, antibunching, and bunching fit parameters, respectively. The values of a, τ_1, and τ_2 obtained by after the fitting of g^2(τ) are summarized in Table I. Although the bunching behavior [seen as a peak in each g^2(τ) profile] is different for each one of the emitters, it is clear that a shelving state observed at RT [33] persists at cryogenic temperatures. Extended photon correlation measurements of up to 0.1 s (see Fig. S3 of Supplemental Material [36]) confirm the absence of additional, longer-lived metastable states, with the g^2(τ) profiles remaining constant for up to 0.1 s.

TABLE I. Parametric values for a, τ_1, and τ_2 obtained by fitting the second-order autocorrelation functions of E1, E2, and E3, assuming three-level system dynamics.

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<th>E1</th>
<th>E2</th>
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<td>a</td>
<td>1.48 ± 0.03</td>
<td>1.71 ± 0.03</td>
<td>0.18 ± 0.04</td>
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<tr>
<td>τ_1 (ns)</td>
<td>1.13 ± 0.13</td>
<td>1.49 ± 0.11</td>
<td>0.79 ± 0.16</td>
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<tr>
<td>τ_2 (ns)</td>
<td>114.92 ± 3.2</td>
<td>74.26 ± 3.09</td>
<td>26.23 ± 7.49</td>
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To obtain lifetime information from emitters E1–E3, time-resolved photoluminescence (PL) measurements were carried out using a 532-nm pulsed excitation laser [Figs. 2(a)–2(c)]. Double-exponential fits (red lines) of the experimental data yielded lifetimes of 1.6, 2.7, and 2.0 ns (where the fast decay component of each fit corresponds to the system response). Based on the measured lifetimes, the calculated Fourier transform limited linewidth $\Gamma_1$ of emitters E1, E2, and E3 are 0.4, 0.2, and 0.3 μeV, respectively. These values are roughly three orders of magnitude lower than the measured linewidths presented above for the three emitters. A similar, large deviation in the natural linewidth has been reported previously in off-resonantly excited single GaN and InGaN QDs, and it is associated with spectral diffusion [37,38].

Next, we investigate the photophysics of multiple emitters at RT. We measured the brightness of ten SPEs and extracted the maximum fluorescence intensity of each emitter. Figure 4(a) shows an example of background-corrected, power-dependent saturation behavior for a representative emitter in GaN. It has a RT ZPL at 1.818 eV for optimized absorption polarization direction. The power-dependent emission intensities are fitted using the relationship

$$I = I_\infty \frac{P}{P + P_{sat}},$$

where $I_\infty$ is the maximum intensity and $P_{sat}$ is the saturation power, yielding $\sim 105$ kCounts/s and $\sim 558 \mu$W, for the representative emitter. The power-dependent increase in the signal and background count is compared in Fig. S5 [36]. The histograms in Figs. 4(b) and 4(c) summarize the maximum intensity and saturation power for eight additional emitters under optimized absorption polarization condition. The mean value of maximum intensity $I_\infty$ is $(427 \pm 215)$ kCounts/s,
where all emitters are excited using a 532-nm cw laser. This is comparable to other emitters in 3D crystals and can be further improved by employing solid immersion lenses or nanoscale pillars [24,43–45]. The considerable standard deviation observed in the mean fluorescence intensity, as well as the saturation power, $(1270 \pm 735) \mu W$, may arise from discrepancies in the effective absorption of the off-resonant excitation by the different emitters due to their multiple orientations in the film, as is discussed below [46].

Given the variability in brightness of different SPEs in GaN, we investigated the power-dependent antibunching characteristics of individual emitters, at different fractions of their respective saturation powers ($P_{\text{sat}}$). Figures S6(a)–S6(c) show power-dependent, second-order autocorrelation functions for another three emitters at RT, with ZPLs at 1.934, 1.818, and 1.826 eV, respectively (see Figs. S7(a)–7(c) in Supplemental Material [36]). The measurements reveal bunching statistics at intermediate timescales for increasing excitation powers, confirming the involvement of shelving states in the transition kinetics at RT. The power-dependent antibunching characteristics are well fitted using a second-order autocorrelation function accounting for a three-level system [Eq. (S1)], i.e., Eq. (1) rewritten in terms of rates. The antibunching ($\lambda_1$) and bunching ($\lambda_2$) free parameters, as well as bunching measurement factor ($\alpha$), are determined for each one of the three emitters at different powers. The strength of the bunching behavior at different values of $P_{\text{sat}}$ varies between emitters, as expected from the large differences in saturation behaviors discussed above.

By fitting the power-dependent behaviors of $\lambda_1$, $\lambda_2$, and $\alpha$ for each emitter in Figs. S(a)–S(c) via a three-level transition kinetics model, we determine the characteristic rate coefficients and relevant parameters (see Supplemental Material [36]). Table II summarizes these values for each emitter together with their corresponding ZPL energy. The nonradiative decay in $E_b$ and $E_c$ occurs via a power-dependent shelving mechanism with a positive value for $\beta$ (see Supplemental Material [36]). On the other hand, the nonradiative decay in $E_a$ occurs via a power-independent shelving state where $\beta = 0$. The difference in the value of $\beta$ indicates a varying dependence of absorption cross section for the individual shelving state, with varying excitation power.

The excited state lifetime $\tau_{2}$ is calculated for the three emitters using the expression $\tau_{2} = (\kappa_{21} + \kappa_{23})^{-1}$ [47]. As shown in Table III, the emitters have short lifetimes with
The quantity $\tau_{31}$ is given by $1/\kappa_{31}$ or $I_0/\kappa_{31}$ in the case of a power-dependent shelving state [47].

Finally, we focus on the polarization behavior of emitters at RT. Figure 6(a) shows a polar plot from a representative emitter with a RT ZPL at 1.818 eV. The absorption polarization [green] profile is traced using a half-wave plate to highlight the angle at which the minimum and maximum intensities occur. By fixing the half-wave plate at an angle where maximum absorption intensity occurs, and rotating the visible polarizer, we obtain the emission polarization profile for the representative emitters (red) in Fig. 6(a). The polarization data are fitted with the function $I(\varphi) = a + b\cos^2(\varphi)$, where $a$, $b$, and $\phi$ are offset parameter, initial intensity amplitude, and angle between excitation and dipole orientation, respectively [48]. Fitting the emission polarization with this function, we determine the minimum $[I_{\text{min}} = I(\varphi = 90^\circ) = a]$ and maximum $[I_{\text{max}} = I(\varphi = 0) = a + b]$ of the emission (absorption) polarization direction for the representative emitter in Fig. 6(a) to occur at $\sim 135^\circ$ ($60^\circ$) and $\sim 40^\circ$ ($140^\circ$), respectively. Such analysis of polar plots is useful as it allows for the easy determination of the dipole polarization visibility, as well as the relative orientations of the absorption and emission polarization for individual emitters [49–51].

The polarization visibility is given by the intensity contrast equation:

$$I = \frac{I_{\text{max}} - I_{\text{min}}}{I_{\text{max}} + I_{\text{min}}}$$

which, with regard to the emitter shown in Fig. 6(a), yields values for the absorption and emission polarization visibility of 34 and 79%. Notably the absorption is not fully polarized, while the emission is. We carried out similar measurements on 14 additional emitters. Figure 6(b) shows the histogram of their percentile visibility in absorption (green) and emission (red). Interestingly, we observe a significant discrepancy in absorption polarization visibility, which ranges between 26 and 94% with the mean value at ($57 \pm 26$)%.

On the other hand, a mean emission polarization visibility of ($91 \pm 11$)% is obtained for the same emitters. This visibility is a strong indicator that these emitters in GaN are linearly polarized (ideal case $\sim 100$% for a single dipole). We attribute the deviation from the ideal value of the visibility to fluorescence aberrations arising from residual birefringence and imaging through a high-NA (0.9) objective [48,52].

The relative orientation between the absorption and the emission dipoles is further analyzed for the 14 emitters showing a misalignment ranging from 0 to $120^\circ$ as shown

![Fig. 6. Room-temperature polarization spectroscopy of emitters in GaN. (a) Absorption (green) and emission (red) polarization profiles from an emitter with a ZPL at 1.818 eV, exhibiting polarization visibilities of 34 and 79%, respectively. (b) Polarization visibilities of 14 emitters showing that while the emitters are strongly polarized in emission, they show variable degrees of absorption polarization. (c) Histogram of the difference in orientation between absorption and emission polarization.](Image)
by the histogram in Fig. 6(c). This is expected, considering that the emitters are believed to be point defects located in cubic inclusions. Consequently, for off-resonant excitation, absorption may involve a transition to an excited state of the inclusion. The emission transition, however, involves only the highly localized levels of the defect, thus giving a more distinct radial emission direction compared to that of absorption.

To elucidate the nature of the preferential excitation axis, the maximum absorption polarization angle is measured for the 14 emitters and compared to the wurtzite crystal plane directions in Fig. 7. The angle spans all directions, with a maximum occurrence at \( \tilde{\alpha} = 140^\circ \), which corresponds to the [1100] lattice direction of the (0001) wurtzite GaN, as shown in Fig. 7(b). The rotational orientation of the sample was deduced by considering that the sample is mounted with the unit cell along the (0001) plane almost parallel to the excitation field. In this arrangement, rotating the excitation polarization through 180\(^\circ\) sweeps all planes of the hexagonal unit cell. Hence the highest occurrence angle of 140\(^\circ\), which corresponds to the lattice plane direction [1100], is believed to contain the greatest density of cubic inclusions. Furthermore, the highest absorption visibility of 94\% is observed from an emitter with an orientation angle of \( \tilde{\alpha} = 16^\circ \), which corresponds to a minimal out-of-plane orientation. This is expected since confined exciton separation occurs along the c axis, where the excitation is aligned parallel to the c axis [53].

### IV. CONCLUSION

To conclude, we carried out low-temperature spectroscopy of SPEs in GaN. While the FWHM of GaN emitters is significantly narrower at 4 K than at RT, the FWHM does not approach the Fourier transform limited linewidths. Ultrafast spectral diffusion is the most likely explanation for the line broadening where future experimental investigation using approaches such as correlation interferometry should confirm this hypothesis [40]. Temperature-dependent ZPL shift and FWHM broadening results confirm the previously proposed explanation for the existence of a cubic inclusion near the radiative point defect as the cause for the observed S-shaped ZPL shift and nonmonotonic broadening.

A saturation behavior of the emitters was also measured, showing brightness difference among emitters with an average saturation count rate of \((427 \pm 215)\) kCounts/s. The emitters’ kinetics can be described efficiently using a three-level system. Polarization measurements from multiple emitters show high emission visibility of more than 90\% and varying strength in the absorption cross section under excitation with a linearly polarized, off-resonant laser. This work evaluates SPEs in GaN as strong alternatives for application in quantum technologies; at the same time, it highlights bottlenecks hindering their immediate implementation.

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